

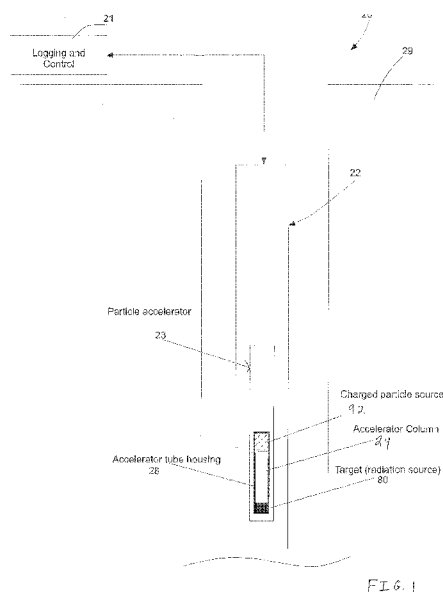


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[Continued on next page]

(54) **Title:** WELL-LOGGING APPARATUS WITH RING-SHAPED RESISTORS AND RELATED METHODS

(57) **Abstract:** A well-logging apparatus may include a charged particle source, a target electrode, and an accelerator column. The accelerator column may include a housing extending between the charged particle source and the target electrode, a series of spaced apart accelerator electrodes carried by the housing, a series of ring-shaped resistors surrounding the housing, and a respective connector coupling adjacent ones of the series of ring-shaped resistors together and to a corresponding one of the series of spaced apart accelerator electrodes.





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WELL-LOGGING APPARATUS WITH RING-SHAPED RESISTORS AND RELATED METHODS

Background

[0001] To determine a porosity of a subterranean formation, it may be desirable to make several simultaneous measurements. One tool for measuring porosity is based on neutron transport through the subterranean formation. The neutron flux attenuated with distance from the source may depend strongly on the hydrogen content of the subterranean formation. For a neutron source, radioactive chemical sources or accelerator based sources are used in existing tools.

[0002] If pore spaces are filled by liquid, the higher porosity corresponds to a higher hydrogen index. The detected neutron counts are generally lower in this case. A properly calibrated tool may increase the accuracy of the porosity measurement in liquid-filled formations if the matrix composition is known. However, the measurement may be affected by various environmental conditions.

[0003] On the other hand, the same measurement may be less accurate for gas-filled subterranean formations when the hydrogen content in the pore spaces is lower due to the relatively low density of the gas. A density measurement may address this ambiguity. For the same porosity of the subterranean formation, the gas-filled and liquid-filled matrices have different densities.

[0004] A charged particle accelerator may include multiple electrodes at different potentials. To charge the electrodes, a voltage source may be used. The voltage source is coupled to a voltage divider, and different outputs of the voltage divider are in turn coupled to different electrodes. Currently, such a

voltage divider is constructed by soldering resistors onto conductive traces on a housing of the electron accelerator.

Summary

[0005] This summary is provided to introduce a selection of concepts that are further described below in the detailed description. This summary is not intended to identify key or essential features of the claimed subject matter, nor is it intended to be used as an aid in limiting the scope of the claimed subject matter.

[0006] A well-logging apparatus may include a charged particle source, a target electrode, and an accelerator column. The accelerator column may include a housing extending between the charged particle source and the target electrode, a series of spaced apart accelerator electrodes carried by the housing, a series of ring-shaped resistors surrounding the housing, and a respective connector coupling adjacent ones of the series of ring-shaped resistors together and to a corresponding one of the series of spaced apart accelerator electrodes.

Brief Description of the Drawings

[0007] FIG. 1 is a schematic diagram of an embodiment of a well-logging system, according to the present disclosure.

[0008] FIG. 2 is a cutaway perspective view of the accelerator column of FIG. 1.

[0009] FIG. 3 is another cutaway perspective view of the accelerator column of FIG. 1.

[0010] FIG. 4 is an enlarged perspective view of the accelerator column of FIG. 1.

[0011] FIG. 5 is a cross-sectional view of the accelerator column of FIG. 1 taken along line 5-5.

[0012] FIG. 6 is another perspective view of the accelerator column of FIG. 1.

[0013] FIG. 7 is another cutaway perspective view of the accelerator column of FIG. 1.

[0014] FIGS. 8A-8D are perspective views of the accelerator column of FIG. 1 during assembly.

Detailed Description

[0015] The present description is made with reference to the accompanying drawings, in which example embodiments are shown. However, many different embodiments may be used, and thus the description should not be construed as limited to the embodiments set forth herein. Rather, these embodiments are provided so that this disclosure will be thorough and complete. Like numbers refer to like elements throughout.

[0016] One or more embodiments of the present disclosure will be described below. These described embodiments are only examples of the presently disclosed techniques. Additionally, in an effort to provide a concise description, all features of an actual implementation may not be described in the specification. It should be appreciated that in the development of any such actual implementation, as in any engineering or design project, numerous implementation-specific decisions may be made to achieve the developers' specific goals, such as compliance with system-related and business-related constraints, which may vary from one implementation to another. Moreover, it should be appreciated that such a development effort might be complex and time consuming, but would nevertheless be a routine undertaking of design, fabrication, and manufacture for those of ordinary skill having the benefit of this disclosure.

[0017] Generally speaking, a well-logging apparatus may include a charged particle accelerator, which may be used to

generate x-rays or neutrons. The accelerator column may include a high voltage source and an accelerator tube installed in a housing. The accelerator tube may include a tube envelope extending between the charged particle source and the target electrode, spaced apart accelerator electrodes carried by the housing, ring-shaped resistors surrounding the housing, and a respective connector coupling adjacent ones of the ring-shaped resistors together and to a corresponding one of the spaced apart accelerator electrodes.

[0018] Referring now to FIGS. 1-7, a well-logging system **20** according to the present disclosure is now described. The well-logging system **20** illustratively includes a well-logging apparatus **22** inserted into a wellbore in a subterranean formation **29**, and a logging and control device **21** on the surface of the subterranean formation and coupled to the well-logging apparatus. In other embodiments, the logging and control device may be integrated in the well-logging apparatus **22**, such as Logging While Drilling (LWD) applications.

[0019] The well-logging apparatus **22** includes a particle accelerator (e.g. particle accelerator) **23** comprising an accelerator column **24**, a charged particle source **92** adjacent the accelerator column, and a target electrode (i.e. radiation source) **80** at an opposite end of the accelerator column. The accelerator column **24** is between the charged particle source **92** and the target electrode **80**. As will be appreciated, the accelerator column **24** defines an electric field that accelerates charged particles (e.g. electron or positively charged particles, such as deuterons or tritons) along a path of travel **41** (FIG. 5) from the charged particle source **92** to the target electrode **80**. As will be appreciated, some elements from the well-logging apparatus **22** have been omitted from the drawings for clarity. For example, the accelerator tube may include a

gas reservoir providing an ionizable gas for the charged particle source **92** (ion source) in a housing (i.e. accelerator tube backbone) **28**, an electron emitting cathode and associated cathode grid adjacent the gas reservoir, and an extractor electrode between the target electrode **80** and the accelerator column **24**.

[0020] The accelerator column **24** illustratively includes the housing **28** extending between the charged particle source **92** (i.e. the generator of the charged particles) and the target electrode **80**, and a series of spaced apart accelerator electrodes **32a-32d** carried by the housing. In particular, the series of spaced apart accelerator electrodes **32a-32d** may be carried on the interior of the housing **28**. In the illustrated embodiment, the accelerator electrodes **32a-32d** comprise conductive rings encircling the path of travel **41**. The series of spaced apart accelerator electrodes **32a-32d** have corresponding voltages applied thereto to provide the aforementioned voltage ramp.

[0021] In the illustrated embodiment, the accelerator electrodes **32a-32d** are protruding from the accelerator tube insulator surface. For example, the accelerator tube may comprise a stack of insulator rings and accelerator electrodes **32a-32d** brazed together.

[0022] The accelerator column **24** illustratively includes a series of ring-shaped resistors (tube shaped or cylindrical shaped) **27a-27f** surrounding the housing **28**, and a respective connector **43a-43c** (FIG. 2) coupling adjacent ones of the series of ring-shaped resistors together and to a corresponding one of the series of spaced apart accelerator electrodes **32a-32d**. The ring-shaped resistors **27a-27f** may have a helical shape in some embodiments. In other embodiments, the ring-shaped resistors **27a-27f** may have cylindrical shapes.

[0023] In other words, the connectors **43a-43c** provide an electrically connection between the electrically conductive rings **26a-26g** and thus the adjacent ring-shaped resistors **27a-27f** and the respective accelerator electrode **32a-32d**. The series of ring-shaped resistors **27a-27f** are coupled in series and define an accelerator column for providing the corresponding voltages for the series of spaced apart accelerator electrodes **32a-32d**. The accelerator includes a voltage source (not shown) coupled to the ring-shaped resistors **27a-27f**.

[0024] As will be appreciated, depending on the charged particle, the electric field may proceed from a negative or positive voltage (order of 100 or 100s kV) to a reference voltage (e.g. ground) at the end (i.e. adjacent a target electrode **80**). In other embodiments, the electric field may proceed from the reference voltage (e.g. ground) to a positive or negative voltage. In yet other embodiments, neither target electrode **80** nor charged particle source **92** may be at the reference potential (e.g. ground), rather one of the intermediate electrodes may be as in a bipolar accelerator configuration. Each ring-shaped resistor **27a-27f** in the series may have the same resistance value or may have a varying resistance value. This flexibility may permit application of specific voltage drops at the accelerator electrodes **32a-32d** down the length of the accelerator column **24**. For example, the voltage drop across the series of accelerator electrodes **32a-32d** may be uniform or may vary. Indeed, this may provide a plug-and-play versatility to adjust the potential distribution of the accelerator column **24**.

[0025] In particular and as perhaps best seen in FIG. 4, each ring-shaped resistor **27a-27f** comprises a dielectric substrate **34a-34d**, and a resistive trace **33a-33f** thereon. For example, the dielectric substrate **34a-34d** comprises a ceramic material

(such as alumina, i.e. aluminum oxide), and each resistive trace **33a-33f** may comprise aluminum, for example. Also, as perhaps best seen in FIG. 3, the resistive trace **33a-33f** comprises an electrically resistive trace (e.g. tantalum nitride, ruthenium oxide, etc.) arranged in a spiral around the dielectric substrate **34a-34d**. The resistive trace **33a-33f** may comprise a material with a low temperature coefficient so that the current drawn is independent of temperature.

[0026] In the illustrated embodiment, each adjacent pair of the series of ring-shaped resistors **27a-27f** has recessed edges defining a channel **35a-35g**. In the illustrated embodiment, each connector **43a-43c** comprises an electrically conductive ring **26a-26g** coupling the adjacent ones of the series of ring-shaped resistors **27a-27f** by sitting in the channel **35a-35g** and providing an electrical path between the grooves of adjacent ring-shaped resistors **27a-27f**. In other words, the adjacent pairs of ring-shaped resistors **27a-27f** receive a corresponding one of the electrically conductive rings **26a-26g**. For example, the electrically conductive rings **26a-26g** may comprise canted coil springs.

[0027] In the illustrated embodiment, each adjacent pair of ring-shaped resistors **27a-27f** defines a tongue and groove mechanical interface defining the channel **35a-35g**. One ring-shaped resistor **27a-27f** defines the (electrically conductive material plated surface) tongue and the other ring-shaped resistor defines the groove (or notch, not having electrically conductive material plated thereon) receiving the tongue. The channel **35a-35g** is illustratively plated with an electrically conductive surface, for example, material comprising aluminum, copper. The resistive traces **33a-33f** illustratively spiral from one end's electrically conductive tongue portion of the channel

35a-35g to the opposing end's electrically conductive tongue portion, which defines the next channel.

[0028] As perhaps best seen in FIGS. 3-4, the channel **35a-35g** defined by the adjacent pair of the series of ring-shaped resistors **27a-27f** is not continuous, i.e. there is a gap. In other embodiments, the gap may be quite small so that the electrically conductive rings **26a-26g** remain in contact with a near continuous channel **35a-35g**. The electrically conductive rings **26a-26g** provide a mechanical link between adjacent pairs of ring-shaped resistors **27a-27f** by fitting into the channel **35a-35g** defined therebetween.

[0029] Each electrically conductive ring **26a-26g** defines a resistor tap point in the accelerator column. Additionally, the connectors **43a-43c** also comprise an electrically conductive link **31a-31c** coupling the corresponding one of the accelerator electrodes **32a-32d** to a corresponding tap point. In the illustrated embodiment, the electrically conductive links **31a-31c** each comprises an electrically conductive spring. Although not shown, the housing **28** may include a plurality of openings aligned with the electrically conductive links **31a-31c** so that there is access to the series of spaced apart accelerator electrodes **32a-32d**. Moreover, using the loose tolerances in the tongue and groove interface of the ring-shaped resistors **27a-27f**, the electrically conductive links **31a-31c** may pass through gaps between the ring-shaped resistors. In embodiments where the electrically conductive links **31a-31c** comprise springs, the springs may aid in maintaining the position of the electrically conductive rings **26a-26g** by providing radially inward force thereby also maintaining a solid electrical connection between the adjacent pairs of the ring-shaped resistors **27a-27f**.

[0030] Additionally, the accelerator column **24** further comprises a plurality of spaced apart dielectric spacers **42a-42f**

(FIGS. 8A-8D) between the housing **28** and the adjacent ones of the series of ring-shaped resistors **27a-27f**. In some embodiments, the spaced apart dielectric spacers **42a-42f** may comprise rubber O-rings surrounding the housing **28**. During operation, the well-logging apparatus **22** may be exposed to a wide range of operating temperatures, causing the housing **28** and other components to expand. In some embodiments where the ring-shaped resistors **27a-27f** and the housing **28** comprise different materials (i.e. different coefficients of thermal expansion), the expansion displacement may inadvertently cause the housing to apply stress to the ring-shaped resistors. The spaced apart dielectric spacers **42a-42f** may provide some mechanical give between the housing **28** and the ring-shaped resistors **27a-27f** and reduce stress therebetween. Also, the dielectric spacers **42a-42f** may dampen shock and vibration to the ring-shaped resistors **27a-27f** during use of the accelerator column **24**.

[0031] Also, each connector **43a-43c** illustratively includes a corona ring **25a-25f** surrounding the electrically conductive ring **26a-26g**. In other embodiments, the corona rings **25a-25f** may be omitted. For example, the corona rings **25a-25f** may comprise aluminum, stainless steel, or titanium. As will be appreciated, the corona rings **25a-25f** provide electromagnetic shielding and improve performance, i.e. protecting the resistive traces **33a-33f** from field emissions caused by the strong potential between adjacent electrodes and between the electrodes and the grounded metal housing of the particle accelerator **23**.

[0032] As perhaps best seen in FIG. 5, each corona ring **25a-25f** illustratively includes a recess on an inner radial surface thereof for providing a mechanical coupling to the electrically conductive ring **26a-26g**, i.e. a snap-on fitting. Given this illustrated direct mechanical coupling to the electrically conductive ring **26a-26g**, the corona rings **25a-25g** are at the

same potential as their respective electrically conductive rings. Of course, in other embodiments, the corona rings **25a-25f** using other approaches.

[0033] Another aspect is directed to an accelerator column **24** for a well-logging apparatus **22**. The accelerator column **24** may include a housing **28** to extend between a charged particle source **92** and a target electrode **80**, a series of spaced apart accelerator electrodes **32a-32d** carried by the housing, a series of ring-shaped resistors **27a-27f** surrounding the housing, and a respective connector **43a-43c** coupling adjacent ones of the series of ring-shaped resistors together and to a corresponding one of the series of spaced apart accelerator electrodes.

[0034] Another aspect is directed to a method for making the accelerator column **24** for charged particles. The method includes coupling a series of spaced apart accelerator electrodes **32a-32d** along a housing **28**, coupling a series of ring-shaped resistors **27a-27f** to surround the housing, and coupling a respective connector **43a-43c** between adjacent ones of the series of ring-shaped resistors and to a corresponding one of the series of spaced apart accelerator electrodes.

[0035] Helpfully, the accelerator column **24** may be readily assembled without using small jewelry screws and substantial amounts of soldering and using less manual labor. Further, the accelerator column **24** may readily configured for varying applications by varying the number of ring-shaped resistors **27a-27f** and the resistance of each one.

[0036] Referring now additionally to FIGS. 8A-8D, a method for making the accelerator column **24** is now described. In particular, the method includes first positioning (sliding) a first ring-shaped resistor **27f** onto the housing **28**, and coupling a respective connector **43a-43c**. The coupling of the connector **43a-43c** comprises positioning an electrically conductive link

31a-31c through the housing **28** and to be coupled to the accelerator electrodes **32a-32d**, and positioning a first electrically conductive ring **26g** in a channel **35a-35g** partially defined by the first ring-shaped resistor **27f**. Then, the first corona ring **25g** may be installed on the first electrically conductive ring **26g**.

[0037] The method includes positioned a second ring-shaped resistor **27e** onto the housing **28**, and fitting the respective tongue into the groove of the first ring-shaped resistor **27f**, which completes the channel **35a-35g** between the first and second ring-shaped resistors **27e-27f** and defines a resistor tap point. The method also includes fitting a second corona ring **25f** onto the second electrically conductive ring **26f**. Subsequent resistors are installed in the same fashion as the second resistor.

[0038] Portions of each edge of the substrates **34a-34d** are metalized and coupled to their respective resistor traces **33a-33f**. Since portions of the edges are metalized, and not the entire edge, the un-metalized areas of each edge form a notch. The metalized edges and notches are shaped such that the metalized edge of one ring-shaped resistor **27a-27f** may fit into the notch of another ring-shaped resistor to establish mechanical contact, and/or to align the ring-shaped resistors. The alignment of the metalized edges and notches may be such that the conductive rings "see" one nearly continuous metalized groove.

[0039] While one particular way of mechanically coupling the electrically conductive rings **26a-26g** to the spaced apart accelerator electrodes **32a-32d** is illustrated, those of skill in the art will recognize that other ways of mechanically coupling the electrically conductive rings to the accelerator electrodes are usable and are within the scope of this disclosure. For

example, instead of spring connectors, there may be wires long so as to maintain electrical contact when the distance between the housing **28** and the electrically conductive rings **26a-26g** changes. These wires may be spot welded to the accelerator electrodes **32a-32d**, then hooked around the corona rings **25a-25f**, or may be spot welded to the corona rings as well.

[0040] Since the electrical connections made between the resistors of the accelerator column **24** are mechanical, soldering is not performed during assembly. Due to this lack of soldering, and the ease of sliding the ring-shaped resistors **27a-27f** onto the housing **28**, installation time of this accelerator column on the housing is reduced compared to prior approaches. This also enables quick replacement of a broken resistor, as well as quick testing of ring-shaped resistors **27a-27f** so as to match sets of resistors to each other.

[0041] While the disclosure has been described with respect to a limited number of embodiments, those skilled in the art, having benefit of this disclosure, will appreciate that other embodiments can be envisioned that do not depart from the scope of the disclosure as disclosed herein.

THAT WHICH IS CLAIMED IS:

1. A well-logging apparatus comprising:
a charged particle source;
a target electrode; and
an accelerator column comprising
a housing extending between said charged particle source and said target electrode,
a series of spaced apart accelerator electrodes carried by said housing,
a series of ring-shaped resistors surrounding said housing, and
a respective connector coupling adjacent ones of said series of ring-shaped resistors together and to a corresponding one of said series of spaced apart accelerator electrodes.
2. The well-logging apparatus according to Claim 1 wherein each ring-shaped resistor comprises a dielectric substrate and a resistive trace thereon.
3. The well-logging apparatus according to Claim 2 said dielectric substrate comprises a ceramic material.
4. The well-logging apparatus according to Claim 2 wherein said resistive trace comprises an electrically resistive trace arranged in a spiral around said dielectric substrate.
5. The well-logging apparatus according to Claim 1 wherein each connector comprises:

an electrically conductive ring coupling the adjacent ones of said series of ring-shaped resistors and defining a resistor tap point; and

at least one electrically conductive link coupling the corresponding one of said accelerator electrodes to a corresponding tap point.

6. The well-logging apparatus according to Claim 5 wherein the adjacent ones of said series of ring-shaped resistors have recessed edges defining a channel to receive a corresponding one of said electrically conductive rings.

7. The well-logging apparatus according to Claim 5 wherein said at least one electrically conductive link comprises at least one electrically conductive spring.

8. A method for making an accelerator column for charged particles comprising:

coupling a series of spaced apart accelerator electrodes along a housing;

coupling a series of ring-shaped resistors to surround the housing; and

coupling a respective connector between adjacent ones of the series of ring-shaped resistors and to a corresponding one of the series of spaced apart accelerator electrodes.

9. The method according to Claim 8 wherein each ring-shaped resistor comprises a dielectric substrate and a resistive trace thereon.

10. The method according to Claim 9 the dielectric substrate comprises a ceramic material.

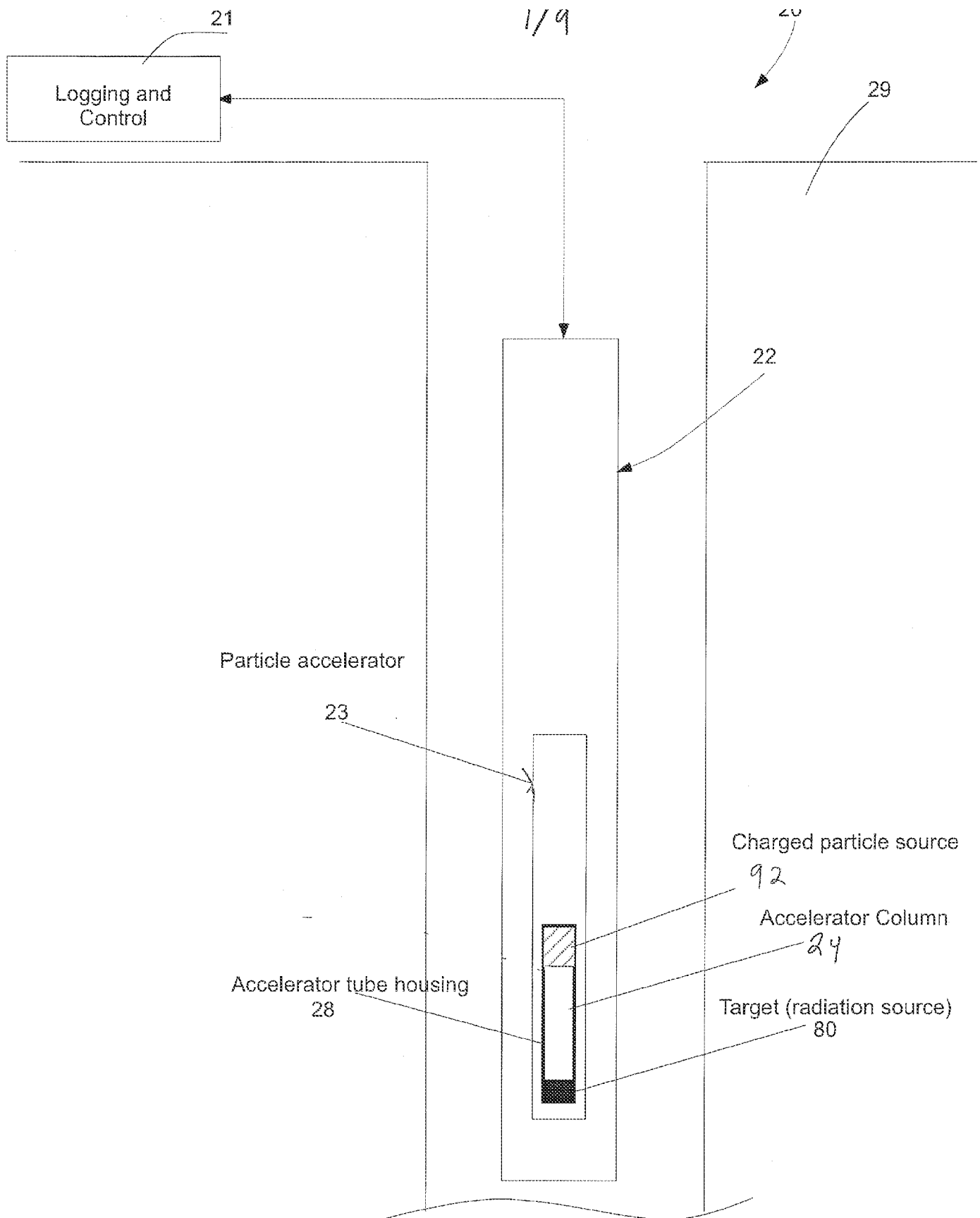


FIG. 1

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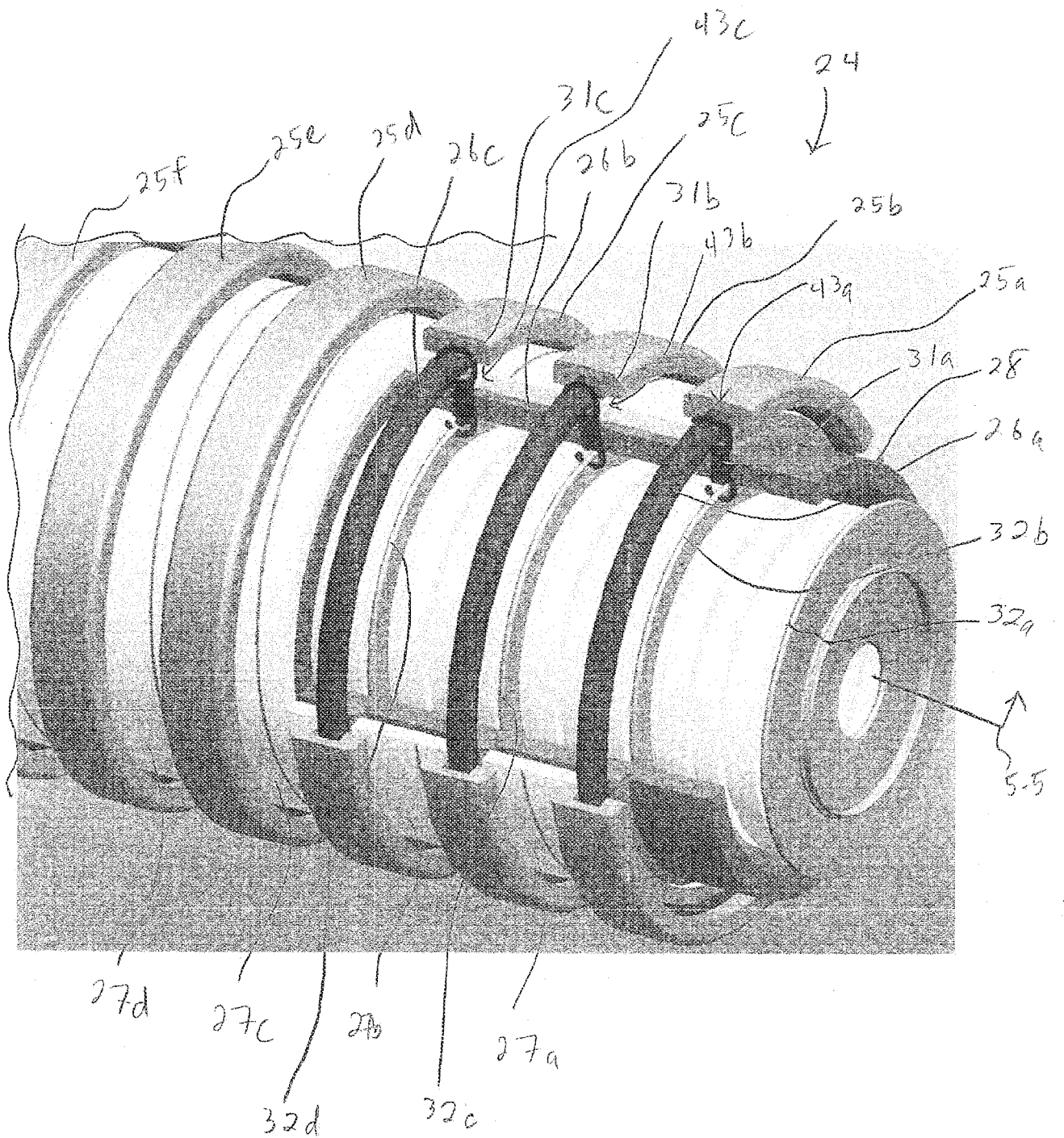


FIG. 2

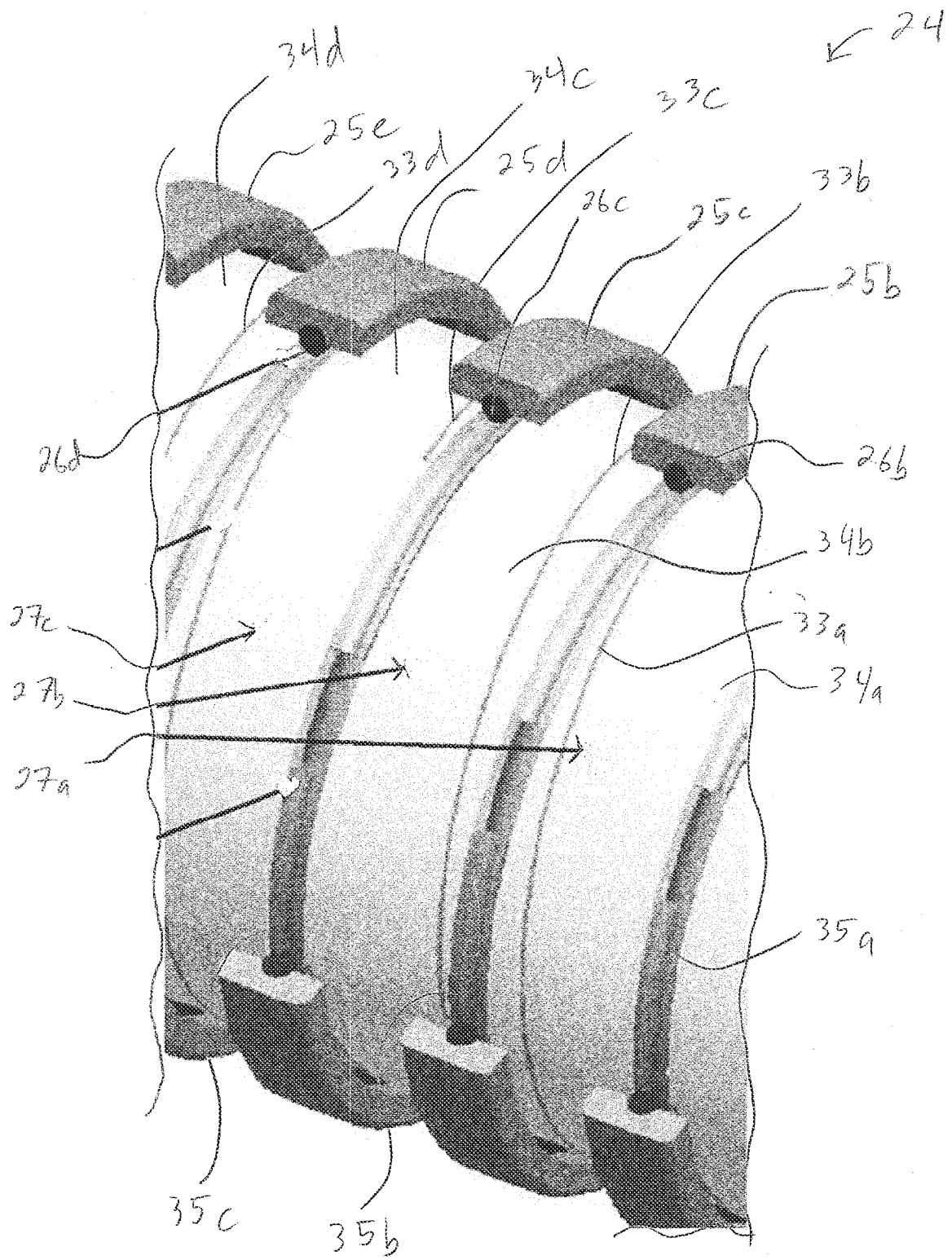


FIG. 3

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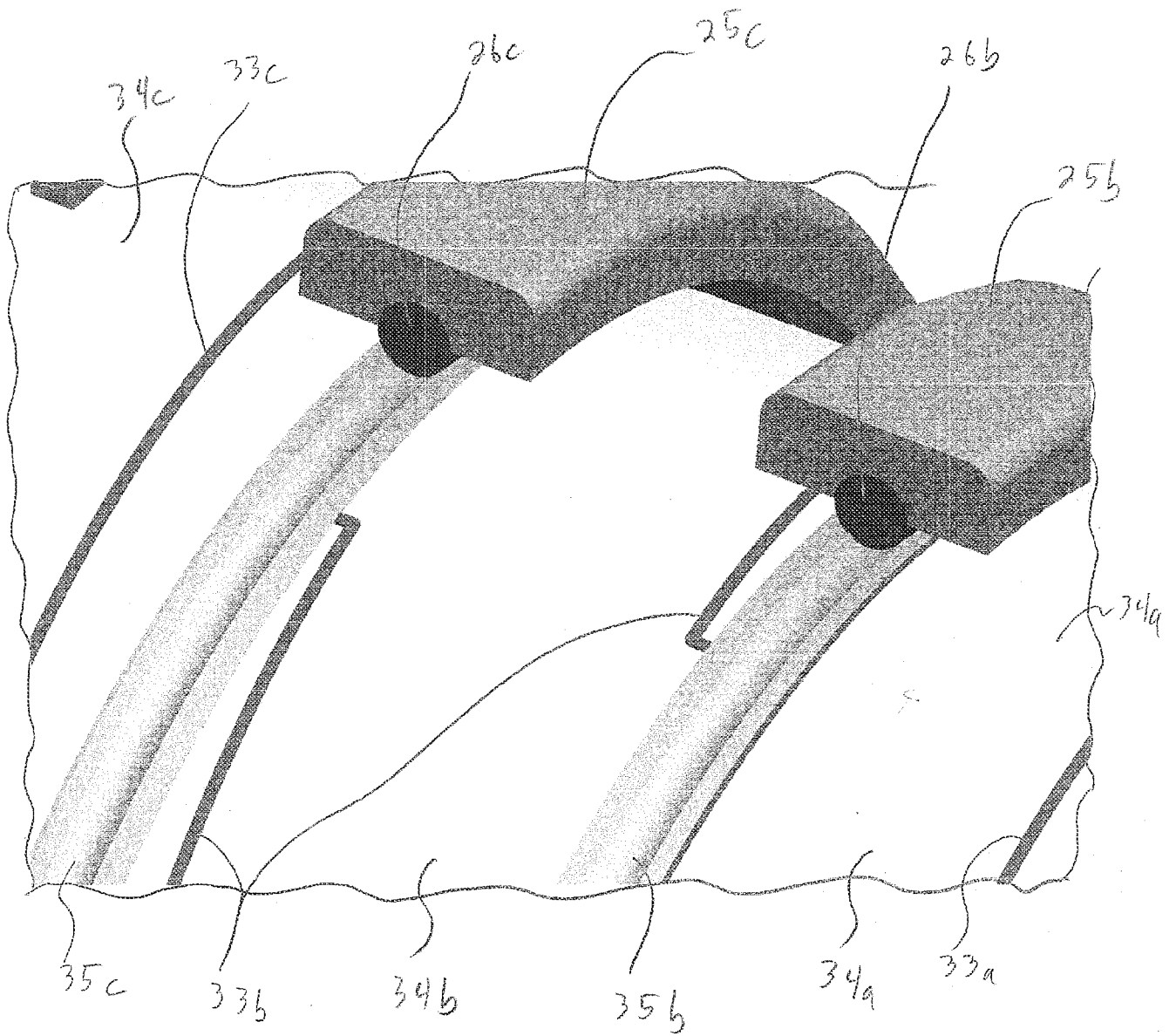


FIG. 4

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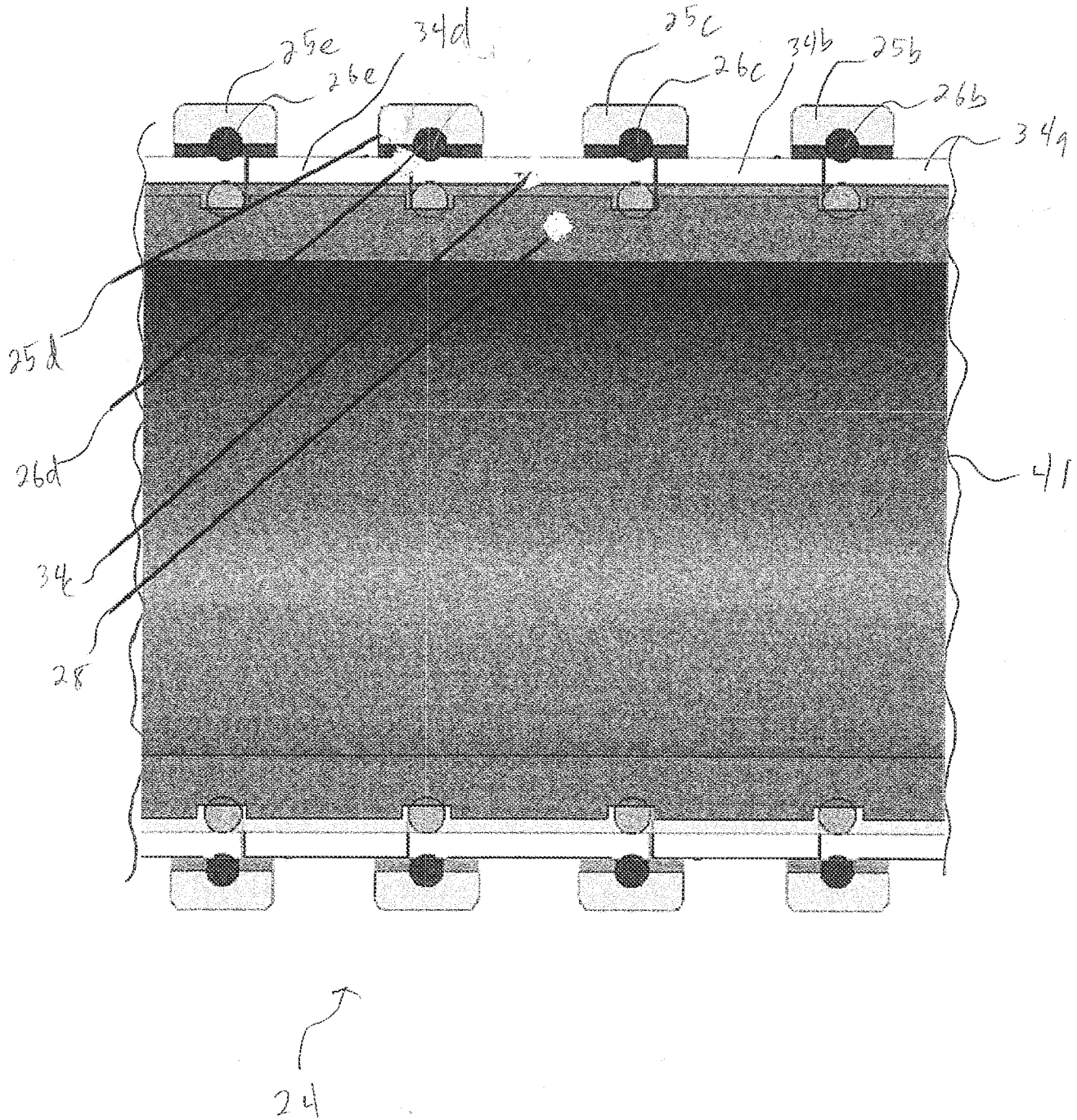


FIG. 5

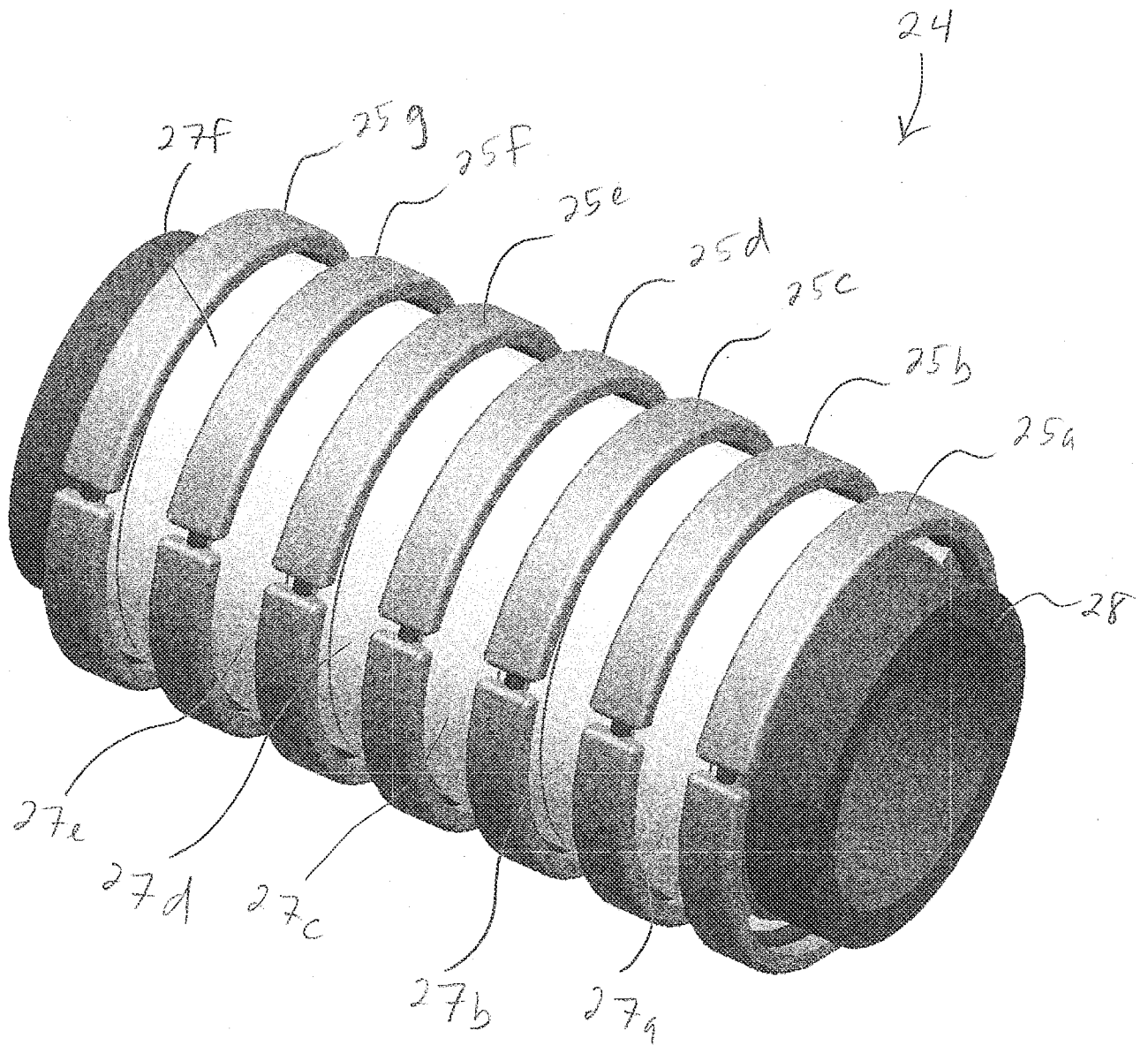


FIG. 6

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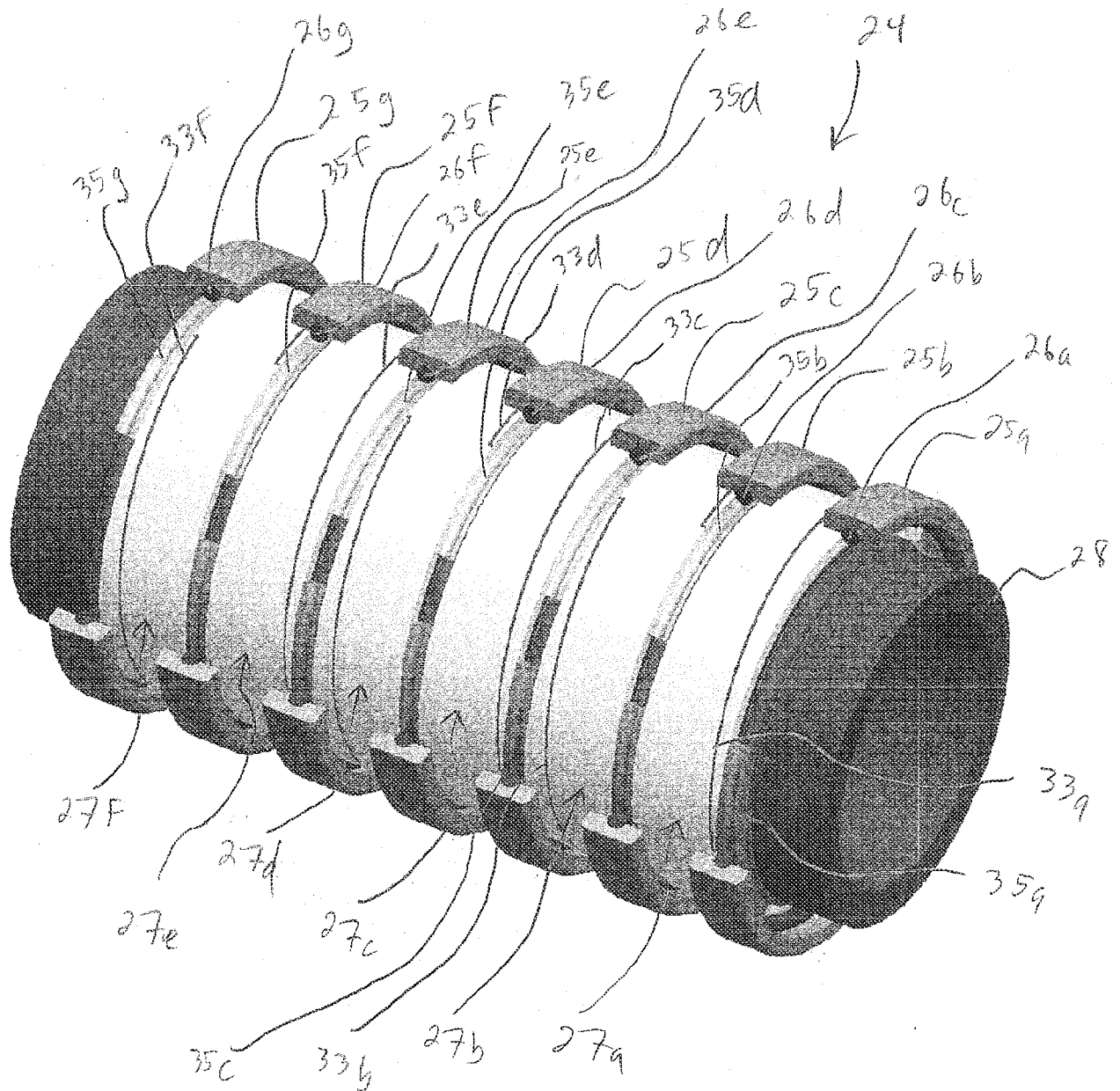


FIG. 7

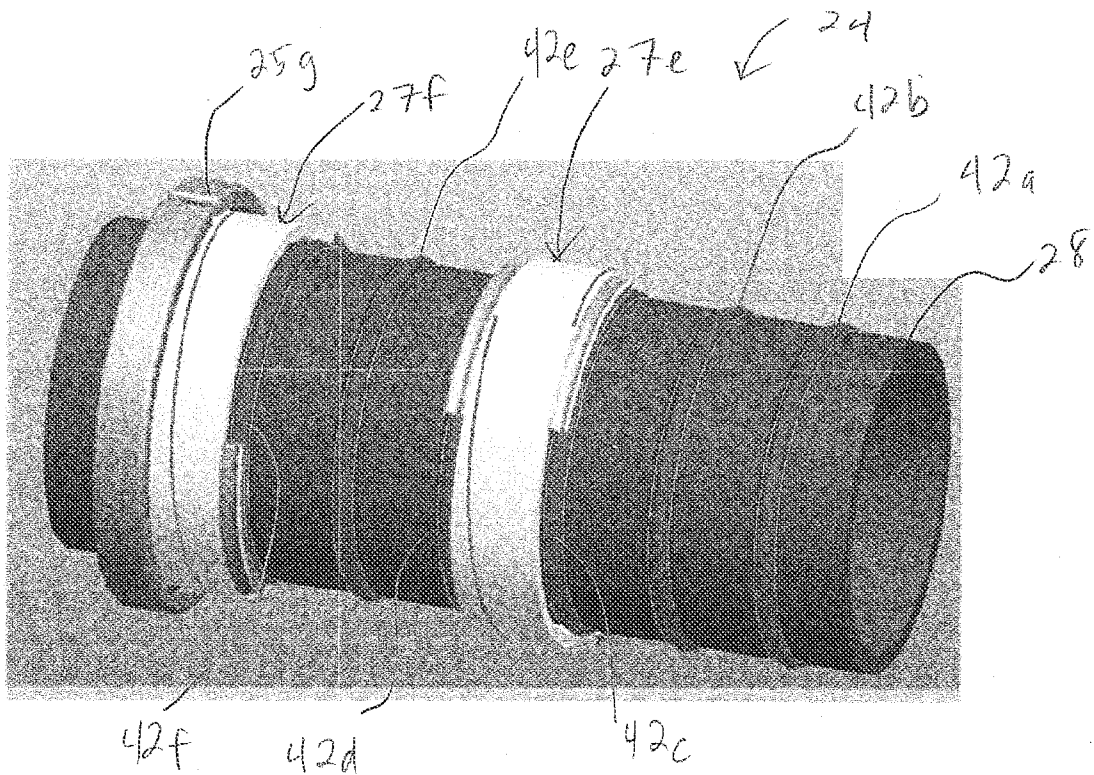


FIG. 8A

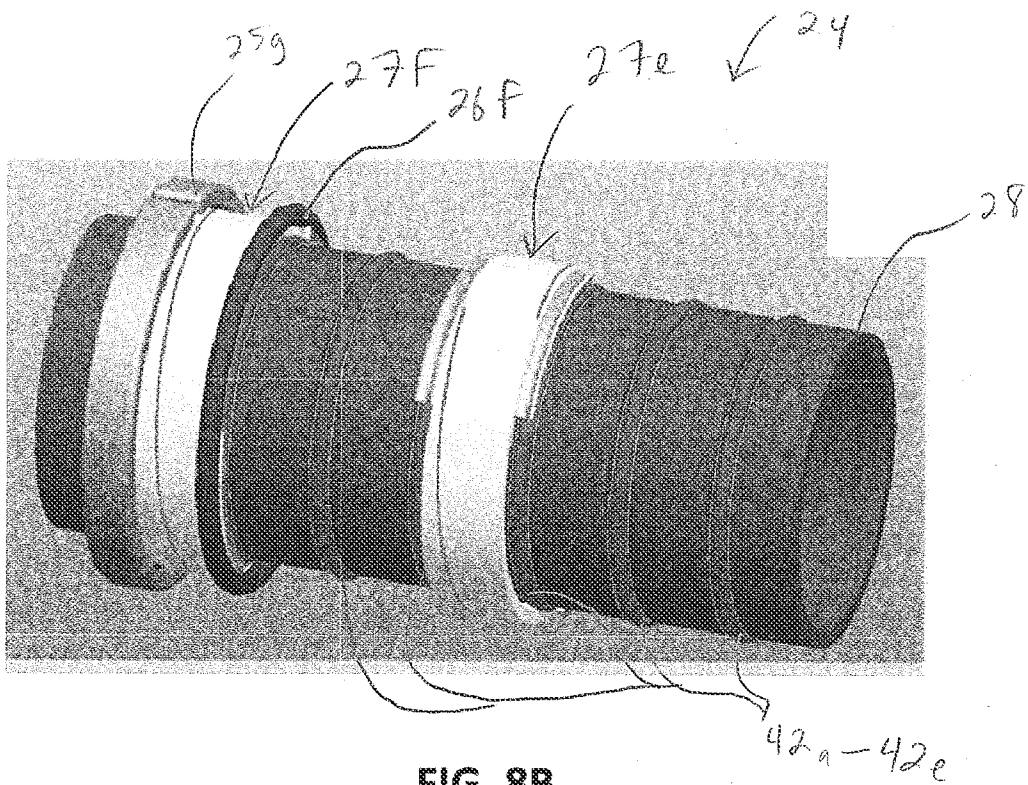


FIG. 8B

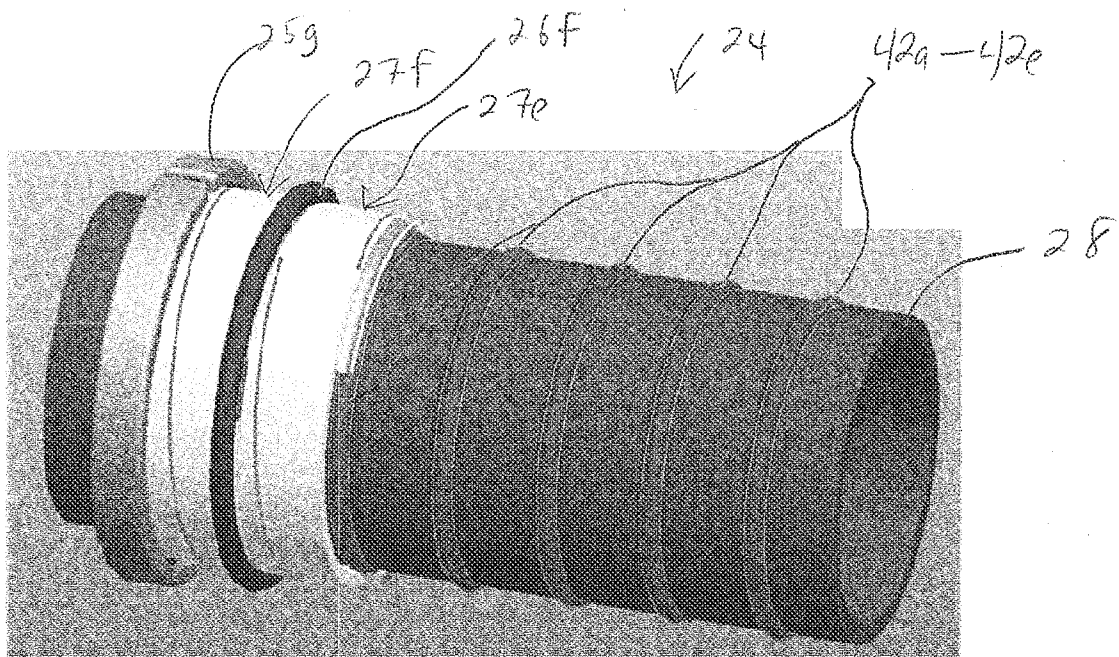


FIG. 8C

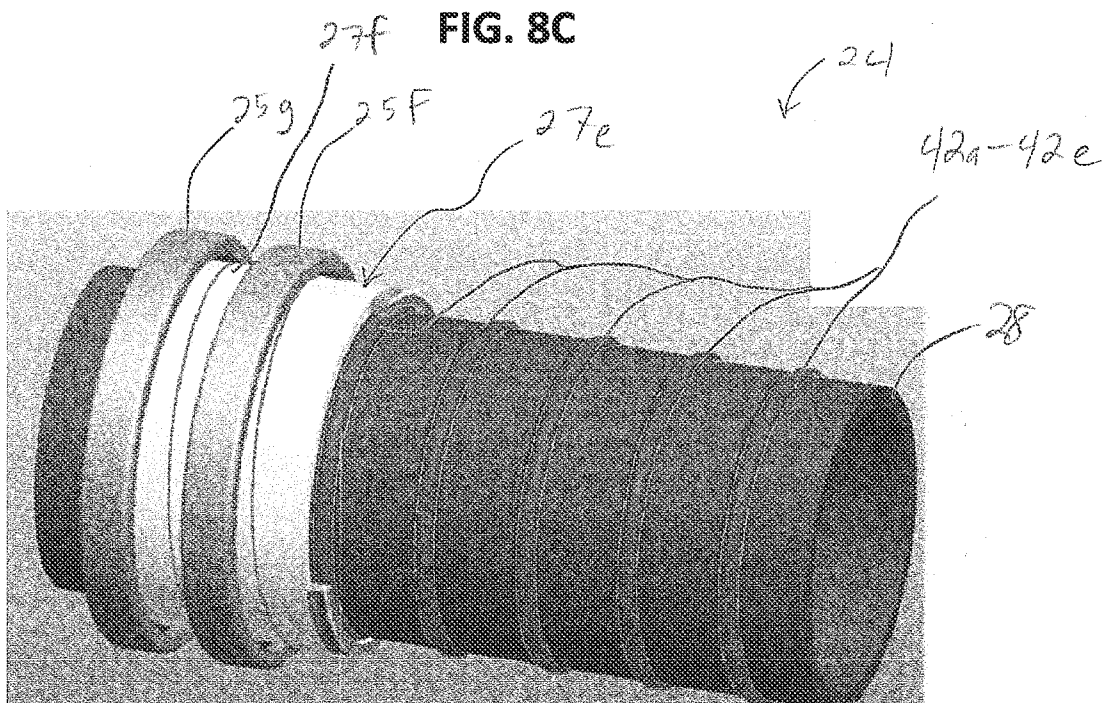


FIG. 8D

INTERNATIONAL SEARCH REPORT

International application No.

PCT/US 2013/034514

A. CLASSIFICATION OF SUBJECT MATTER

G01V 5/08 (2006.01)

According to International Patent Classification (IPC) or to both national classification and IPC

B. FIELDS SEARCHED

Minimum documentation searched (classification system followed by classification symbols)

G01V 5/08, 5/00, 5/04, 5/10, 5/12, 5/14, H05H 3/06

Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched

Electronic data base consulted during the international search (name of data base and, where practicable, search terms used)

PatSearch (RUPTO internal), Esp@cenet, PAJ, USPTO

C. DOCUMENTS CONSIDERED TO BE RELEVANT

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
A	US 3924138 A (DRESSER INDUSTRIES, INC.) 02.12.1975	1-10
A	US 6297507 B1 (TSINGHUA UNIVERSITY et al.) 02.10.2001	1-10
A	US 724441 A (SCHLUMBERGER WELL SURVEYING CORPORATION) 23.02.1955	1-10
A	RU 2316835 C1 (FEDERALNOE GOSUDARSTVENNOE UNITARNOE PREDPRIYATIE "VSEROSSYSKY NAUCHNO-ISSLEDOVATELSKY INSTITUT AVTOMATIKI IM. N. L. DUKHOVA") 10.02.2008	1-10



Further documents are listed in the continuation of Box C.



See patent family annex.

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